

**REMARKS**

Claims 1-3 are pending in the application, and stand rejected under 35 U.S.C. §102(e) as being anticipated by Segal (US 6,574,130).

The Examiner has requested that Applicants particularly point out support for "a defined patch of nanotube fabric" in priority application 09/915,093 (now US Patent No. 6,919,592) in order to receive the priority date. Applicants refer the Examiner to Fig. 3 of the priority application, which clearly shows defined ribbons 101 of nanotube fabric, i.e., defined patches of nanotube fabric. The priority document describes forming the ribbons 101 from a layer or film 312 of carbon nanotubes:

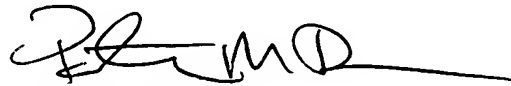
A photoresist may then be applied to the layer 312 and patterned to define ribbons in the matted layer of nanotubes 213. The ribbon patterns cross (for example, perpendicularly) the underlying traces 104. The photoresist is removed to leave ribbons 101 of non-woven nanotube fabric lying on planar surface 306 (US Patent No. 6,919,592 at col. 6, lines 15-21).

In other words, ribbons of nanofabric are defined and patterned in a matted layer of nanotubes. As the plain meaning of "patch" is simply "a piece of material," Applicants submit one of skill in the art would readily appreciate the defined ribbons 101 of nanotube fabric, described in the priority application, to be defined patches of nanotube fabric.

In view of the above remarks, Applicants believe the pending application is in condition for allowance, and therefore respectfully request the Examiner allow the claims to issue. No other fees are believed to be due at this time. However, please charge any fees, or credit any overpayments, to Deposit Account No. 08-0219.

Respectfully submitted,

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